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REQUEST FOR ACCESS TO AN APPLICATION UNDER 37 CFR 1.14(e)

In re Application of <u>Moss</u>	
Application Number <u>09/122484</u>	Filed <u>7/24/98</u>
Art Unit	Examiner

Paper No. _____

Assistant Commissioner for Patents
Washington, DC 20231

1. ☐ I hereby request access under 37 CFR 1.14(e)(2) to the application file record of the above-identified ABANDONED Application, which is not within the file jacket of a pending Continued Prosecution Application (CPA) (37 CFR 1.53(d)) and is: (CHECK ONE)

☒ (A) referred to in:

United States Patent Application Publication No. _____, page _____, line _____,

United States Patent Number 6160876, column _____, line _____, or

an International Application which was filed on or after November 29, 2000 and which

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☐ (B) referred to in an application that is open to public inspection as set forth in 37 CFR 1.11(b) or

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2. ☐ I hereby request access under 37 CFR 1.14(e)(1) to an application in which the applicant has filed an authorization to lay open the complete application to the public.

Deborah A. Beavers
Signature

Date

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